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PHARYNX LID MASK AIRWAY AND PRODUCTION THEREOF

Abstract:

PROBLEM TO BE SOLVED: To provide an improved pharynx lid mask assembly and its production.

SOLUTION: This pharynx lid mask assembly has a mask section formed from a flexible bag 16 surrounding an instrument 15 adhered on the patient side terminal part of a tube 1. The bag 16 is sealed to the instrument 15 around an opening 22 at the patient side terminal part of the tube. A neck 23 of the bag 16 is sealed to the tube 1 at the back of an opening 5 from an expansion lumen 2 so that the bag is expanded to form a cushion 30 on the fore surface of the instrument 15. The instrument 15 is bent backward around an outer end 20 and besides, the bag 16 is expanded away from the rear surface of the instrument so as to provide an expandable cushion 31 existent behind the instrument.

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